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The spectrum from van der Waals to donor-acceptor bonding†

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The chemical bond between halogenated borane Lewis acids and a variety of Lewis bases of varying strength (from strong to weak: NH3, MeCN, N2) has been quantum chemically explored using dispersioncorrected relativistic density functional theory (DFT) at ZORA-BLYP-D3(BJ)/TZ2P. We propose a unified picture of chemical bonding that exists on a continuum where weaker van der Waals (commonly referred to as "noncovalent") interactions at longer distances transition into stronger donor-acceptor (commonly referred to as covalent) complexes at shorter distances. Remarkably, depending on the strength of the Lewis base, an intermediate regime is observed where both van der Waals and donor-acceptor complexes are observed. This study demonstrates that a covalent component is ubiquitous across the bonding spectrum, with the stability of the minima on potential energy surfaces determined by the strength of the Lewis acid-base interaction. We advocate for classifying Lewis pairs as strongly or weakly bonded based on whether their covalent interaction is strong enough to overcome the geometric penalty of bond formation. This work elucidates the fuzzy boundaries within chemical bonding.

Introduction

Chemical bonding is fundamental to all areas of chemistry as it dictates molecular structure, stability, and reactivity, influencing diverse fields from organic synthesis and catalysis to materials science and biochemistry.1 A deep understanding of chemical bonding enables the rational design of new molecules and materials with tailored properties,2 impacting advancements in drug discovery,3 energy storage,4 and nanotechnology.5

Covalent or donor-acceptor bonding, as defined by IUPAC, involves a region of accumulated electron density between nuclei, arising from electron sharing.⁶ Covalent bond energies typically span 40 to 150 kcal mol⁻¹ for single bonds involving main block elements, with bond distances generally ranging from 0.9 to 2.0 Å, depending on the size and electronegativity of the bonded atoms.7 Advanced quantum chemical investigations have illuminated the nature of bonding between atoms or fragments A and B through analysis of the electronic wavefunction, providing invaluable insights into molecular structure and reactivity.8 A more nuanced and accurate perspective of the chemical bond beyond simple electron sharing acknowledges the synergy of multiple interactions within

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covalent bonds, including electrostatic attraction, Pauli repulsion, orbital interactions, and dispersion interactions.8

At the opposite end of the chemical bonding range, we have the intermolecular (commonly referred to as "noncovalent") interactions that often correspond to any interaction that is weaker than covalent bonds but typically present bond strengths below 15 kcal mol⁻¹. These interactions exhibit a rich diversity and encompass a broad spectrum in their own right, including ionic,9 hydrogen bonding,10 halogen bonding,11 chalcogen bonding, 12 pnictogen bonding, 13 π-interactions, 14 and van der Waals forces (dipole-dipole interactions, dipole-induced dipole interactions, and induced dipole-induced dipole interactions), 15 significantly expanding the chemical bonding landscape. 16 These intermolecular interactions play a crucial role in molecular recognition and are essential for maintaining the structural integrity of biomolecules, supramolecular assemblies, and materials. 17

Recent research has illuminated the nuanced nature of intermolecular interactions and covalent bonds, revealing that their boundaries are not always distinct. 18 For example, it has been shown that traditional intermolecular interactions, such as hydrogen, 10c,10e,10f chalcogen, 12c and pnictogen bonding, 13 can contain a substantial covalent character due to stabilizing donor-acceptor interactions. These strengthened interactions can exhibit bond lengths and energies comparable to traditional covalent bonds, challenging the conventional dichotomy between covalent and noncovalent bonding. Recent studies have also shown that intermolecular interactions can be strengthened to the point where they resemble covalent bonds,

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$$X = F$$
, CI, Br, I $X_3B \leftarrow LB$ and/or $X \times X$
 $X = F$, CI, Br, I $X_3B \leftarrow LB$ $X_3B \cdots LB$

LB = NH₃, MeCN, N₂ donor-acceptor van der Waals (vdW)

Scheme 1 The Lewis acid-base pairs analyzed in this work

blurring the traditional boundaries between these two types of bonding motifs.19

In this work, we quantum-chemically explore the chemical bonding realm in Lewis acid-base pairs using boron trihalides BX_3 ($X_3 = F_3$, Cl_3 , Br_3 , I_3) as Lewis acids and Lewis bases of varying strength (from strong to weak: NH₃, MeCN, N₂; Scheme 1).

Similar to the covalent bond and intermolecular interactions dichotomy aforementioned, Lewis pairs are often classified as donor-acceptor or van der Waals depending on the stability and nature of the final adducts.²⁰ Donor-acceptor complexes are classified as strong, short-bonded, and covalent in nature, whereas van der Waals complexes are weak, long-bonded, and held together by electrostatic and dispersion interactions (Fig. 1). Herein, we furnish a unified theory of a chemical bonding spectrum, which shows not only that the boundaries are fuzzy in definition but also how a bond can be tuned from one end of the spectrum to another. We advocate for the definition of a bond as strong or weak and, therefore, of Lewis pairs classified as strongly or weakly bonded. What distinguishes one Lewis pair from the other is whether the interaction between the Lewis acid and the Lewis base is strong enough to overcome the geometrical penalty inherent to the chemical bond formation. The nature of this bond is a consequence of the molecular context.

Methods

Computational details

All calculations were performed using the Amsterdam density functional (ADF) program (ADF2019.305).21 Geometries and

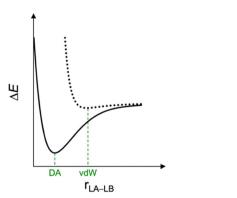


Fig. 1 Potential energy surface for the van der Waals (vdW) and donor-acceptor (DA) bonding schemes between a Lewis acid (LA) and Lewis base (LB).

energies were calculated at the BLYP level of the generalized gradient approximation (GGA).22 The DFT-D3(BJ) method developed by Grimme and coworkers was used to correct for dispersion interactions.²³ Scalar relativistic effects were accounted for using the zeroth-order regular approximation (ZORA).²⁴ Molecular orbitals (MOs) were expanded using a large, uncontracted set of Slatertype orbitals (STO): TZ2P.²⁵ The TZ2P basis set is of triple-ζ quality, augmented by two sets of polarization functions, All electrons were treated variationally. The accuracies of the fit scheme (Zlm fit)²⁶ and the integration grid (Becke grid)²⁷ were set to VERY GOOD. All Lewis pairs X₃B-LB (X₃ = F₃, Cl₃, Br₃, I₃; LB = NH₃, MeCN, N₂) were optimized with both C_1 (i.e., without) and C_{3v} symmetry constraints. All optimized structures were inspected to be true minima through vibrational analyses (no imaginary frequencies).²⁸ Only for the long-bonded adducts I₃B-LB (LB = MeCN, N_2) in C_{3v} symmetry we found two small imaginary frequencies (ca. -10 cm^{-1}) because the adducts are not entirely linear along the B-N-Y (Y = C and N, respectively) bond axis. Additionally, except for X_3B -NCMe (X = Br, I), in which MeCN approaches the Lewis acid laterally by the $C \equiv N$ bond, the geometrical and energetic differences between the C_1 and C_{3v} structures are minimal (less than 0.02 Å and 0.1 kcal mol⁻¹). We have therefore used the Lewis pairs with C_{3v} symmetry throughout this work, as it allows us to decompose the orbital interaction into its irreducible representation contributions and a more equitable comparison between all studied adducts (the Cartesian coordinates of all studied species are provided in the ESI†). The molecular structures were illustrated using CYLview.²⁹

Activation strain and energy decomposition analyses

Insight into the nature of Lewis acid-base pairs is obtained by applying the activation strain model (ASM)³⁰ in conjunction with quantitative Kohn-Sham molecular orbital (KS-MO)31 theory and a matching energy decomposition analysis (EDA)³² along the X₃B-LB bond formation. The potential energy surface along the B-N bond formation was scanned in a stepwise manner from 1.00 to 4.00 Å with 0.005 Å per step, resulting in 121 steps in total. The overall bond energy ΔE is then decomposed into the respective total strain and interaction energy, $\Delta E_{\rm strain}$ and $\Delta E_{\rm int}$, and these values are projected onto the B-N bond distance [eqn (1)]:

$$\Delta E = \Delta E_{\text{strain}} + \Delta E_{\text{int}} \tag{1}$$

The strain energy ΔE_{strain} is the amount of energy required to deform the Lewis acid BX3 and Lewis base LB from their equilibrium structure to the geometry that they acquire in the final complex. Whereas the interaction energy ΔE_{int} corresponds to the actual energy change when the geometrically deformed BX₃ and LB fragments are combined to form X₃B-LB.

We further analyze the interaction energy $\Delta E_{\rm int}$ within the framework of the Kohn-Sham molecular orbital (KS-MO)30 model by dissecting it using our canonical energy decomposition analysis (EDA)32 scheme into electrostatic interactions, Pauli repulsion, (attractive) orbital interactions, and dispersion corrections [eqn (2)]:

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 $\Delta E_{\text{int}} = \Delta V_{\text{elstat}} + \Delta E_{\text{Pauli}} + \Delta E_{\text{oi}} + \Delta E_{\text{disp}}$ (2)

The electrostatic energy $\Delta V_{\rm elstat}$ corresponds to the electrostatic interactions between the unperturbed charge distributions of the fragments BX3 and LB, which is usually attractive. The Pauli repulsion ΔE_{Pauli} comprises the destabilizing interactions between occupied orbitals on either fragment (more precisely, between same-spin occupied spin-orbitals on either fragment) and arises from the antisymmetrization of the Hartree wavefunction due to the Pauli principle. The orbital interactions ΔE_{oi} term accounts for charge transfer (donor-acceptor interaction between an occupied orbital of one fragment with an empty orbital of the other fragment) and polarization (empty/ occupied orbital mixing on one fragment due to the presence of another fragment). Finally, the dispersion energy $\Delta E_{\rm disp}$ is added using Grimme's empirical correction.²³ The PyFrag2019 program was used to facilitate these analyses.³³

Results and discussion

The geometries and bond energies of the X₃B-LB Lewis pairs $(X_3 = F_3, Cl_3, Br_3, I_3; LB = NH_3, MeCN, N_2)$ are analyzed and discussed. The results are summarized in Fig. 2, with detailed structural data in Table S2 of the ESI.† The strength of the B-N bond in the X₃B-LB Lewis pairs diminishes as the Lewis base varies from NH₃ to MeCN to N₂ (Fig. 2). Specifically, the strong Lewis base NH₃ forms only strongly bonded adducts with boron trihalides that go with B-N bond lengths of 1.6-1.7 Å and bonding energies (ΔE) ranging from -18.4 to -26.2 kcal mol⁻¹. Upon forming strongly bonded adducts, the Lewis acid (BX₃) undergoes a higher degree of pyramidalization, deviating from its trigonal planar equilibrium geometry. This structural adjustment involves decreasing the θ_{X-B-X} bond angle and increasing the r_{B-X} bond length (Table S2, ESI†). We have previously shown that the rigidity of the Lewis acids is the causal factor underlying the increase in stability of the X₃B-NH₃ adducts as BX₃ is varied from BF₃ to BI₃.³⁴ In other words, strongly bonded X₃B-LB adducts, which characteristically have higher distortivity, become more stable as X goes from F to Cl to Br to I because the Lewis acid BX3 can more easily deform along this series as the corresponding B-X bond becomes weaker. This offered a new perspective on the previous rationale that ascribed the trends in Lewis acidity of boron trihalides to the strength of frontier molecular orbital interactions.35

In contrast, the weak Lewis base N2 forms only weakly bonded adducts with B-N bond lengths of 2.9-3.4 Å and ΔE values of -1.7 to -2.1 kcal mol⁻¹. In these cases, the Lewis acid is barely deformed from its planar geometry, and the stability of the final adduct varies little and becomes somewhat less stable as BX₃ is varied from BF₃ to BI₃. Note that the trends in Lewis acidity of BX3 towards N2 are exactly the opposite of those towards NH3 discussed above. The reversal in Lewis acidities of

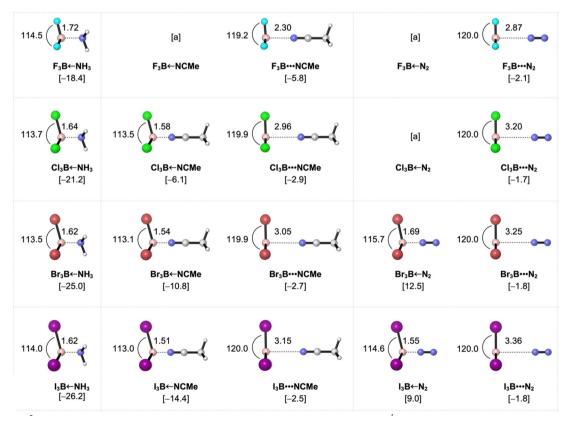


Fig. 2 Geometries (in Å, deg.) and the electronic bond energies ΔE in brackets (in kcal mol⁻¹) of the X_3B-LB Lewis pairs ($X_3=F_3$, Cl_3 , Br_3 , I_3 ; $LB=NH_3$, MeCN, N_2) in C_{3v} symmetry, computed at ZORA-BLYP-D3(BJ)/TZ2P. ^a Lewis adduct does not exist.

Table 1 Activation strain model and energy decomposition analysis terms (in kcal mol^{-1}) computed at the geometries of the X_3B-LB Lewis pairs ($X_3=F_3$, Cl_3 , Br_3 , I_3 ; $LB = NH_3$, MeCN, N_2) in C_{3v} symmetry

X ₃ B–LB	$r_{ m B-N}$	ΔE	$\Delta E_{ m strain}$	$\Delta E_{ m int}$	$\Delta V_{ m elstat}$	$\Delta E_{ m Pauli}$	$\Delta E_{ m oi}$	$\Delta E_{ m disp}$
$F_3B \leftarrow NH_3$	1.718	-18.4	21.1	-39.5	-88.8	123.7	-71.7	-2.7
$F_3B \cdot \cdot \cdot NCMe$	2.303	-5.8	2.8	-8.6	-18.0	21.3	-9.8	-2.1
$\mathbf{F}_{3}\mathbf{B}\cdot\cdot\cdot\mathbf{N}_{2}$	2.874	-2.1	0.1	-2.2	-2.3	3.1	-1.6	-1.3
$Cl_3B \leftarrow NH_3$	1.642	-21.2	21.7	-42.9	-118.4	193.1	-112.2	-5.4
$Cl_3B \leftarrow NCMe^b$	1.583	-6.1	22.1	-28.2	-101.4	193.1	-115.0	-5.0
$Cl_3B \cdot \cdot \cdot NCMe^b$	2.962	-2.9	0.2	-3.1	-5.0	6.5	-1.9	-2.7
$Cl_3B\cdots N_2$	3.203	-1.7	0.0	-1.7	-1.4	2.8	-1.1	-2.0
$Br_3B \leftarrow NH_3$	1.622	-25.0	19.7	-44.7	-126.2	212.8	-125.2	-6.1
$Br_3B \leftarrow NCMe^b$	1.540	-10.8	20.9	-31.7	-114.6	226.0	-137.3	-5.8
$Br_3B \cdots NCMe^b$	3.051	-2.7	0.1	-2.8	-4.0	6.1	-1.9	-3.0
$Br_3B \leftarrow N_2^b$	1.690	12.5	12.2	0.4	-64.8	152.7	-82.6	-5.0
$Br_3B\cdots N_2^{2b}$	3.250	-1.8	0.0	-1.8	-1.3	3.0	-1.2	-2.3
$I_3B \leftarrow NH_3$	1.617	-26.2	17.0	-43.2	-132.9	231.0	-134.0	-7.2
$I_3B \leftarrow NCMe^b$	1.511	-14.4	18.7	-33.1	-129.4	260.5	-157.5	-6.7
$I_3B\cdots NCMe^b$	3.146	-2.5	0.0	-2.5	-3.5	6.3	-1.9	-3.5
$I_3B \leftarrow N_2^b$	1.551	9.0	14.2	-5.2	-97.9	230.2	-131.7	-5.9
$I_3B\cdots N_2^{b}$	3.356	-1.8	0.0	-1.8	-1.3	3.2	-1.1	-2.6

^a Computed at ZORA-BLYP-D3(BJ)/TZ2P. ^b The conversion barrier of the long-bonded to the short-bonded adduct is 1.9, 1.7, 14.3, 2.0, and 13.3 kcal mol⁻¹ for Cl₃B-NCMe, Br₃B-NCMe, Br₃B-N₂, I₃B-NCMe, and I₃B-N₂, respectively (see Table S2).

boron trihalides towards strong versus weak bases is well documented in the literature³⁶ and is effectively reproduced by our DFT computations at ZORA-BLYP-D3(BJ)/TZ2P.

Lastly, the moderate Lewis base MeCN displays bond-stretch isomerism,³⁷ forming both strongly and weakly bonded adducts with boron trihalides, 38 except in the case of BF3, where only the long-bonded adduct is formed. The conversion of the longbonded to the short-bonded adducts proceeds through transition states with a small barrier of ca. 2 kcal mol^{-1} (i.e., 1.9, 1.7, and 2.0 kcal mol⁻¹ for Cl₃B-NCMe, Br₃B-NCMe, and I₃B-NCMe, respectively; see Table 1).

Classifying X_3B -LB Lewis pairs ($X_3 = F_3$, Cl_3 , Br_3 , I_3 ; LB =NH3, MeCN, N2) as either van der Waals or donor-acceptor complexes is not always straightforward. The nature of Lewis

adducts is often classified by the balance of the stabilizing interactions in ΔE_{int} (see eqn (2) in the Methods section), namely, electrostatic stabilization $\Delta V_{\rm elstat}$, orbital interactions $\Delta E_{\rm oi}$, and dispersion $\Delta E_{\rm disp}$. That is donor-acceptor complexes are predominantly stabilized by orbital interactions $\Delta E_{\rm oi}$, whereas van der Waals complexes are mainly electrostatic $\Delta V_{
m elstat}$ and dispersion $\Delta E_{
m disp}$ in nature. However, note that, for example, the Cl₃B←NH₃ adduct, which is classified as a donor-acceptor complex, has a larger electrostatic than orbital interaction contribution ($\Delta V_{\rm elstat} = -118.4 \text{ kcal mol}^{-1}$ and $\Delta E_{\rm oi} =$ -112.2 kcal mol⁻¹, respectively). Similar inconsistencies can be found in Table 1. This illustrates how the classification by nature is not only limited to a few cases but also misleading, as it overlooks the fact that all complexes exhibit a covalent, that

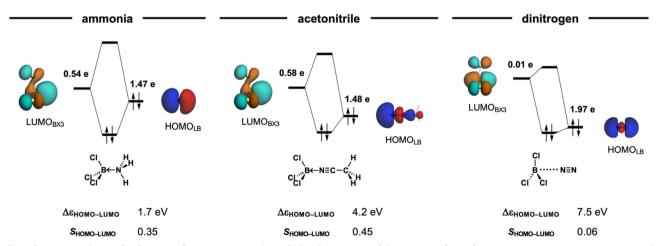


Fig. 3 MO diagram of the $HOMO_{LB}-LUMO_{BX3}$ interaction of the Cl_3B-LB Lewis pairs (LB = NH_3 , MeCN, N_2) at their equilibrium geometries. Isosurface (at 0.03 au), gross Mulliken populations (in electrons), orbital energy gap (in eV), and orbital overlap of the HOMO_{LB} and LUMO_{BX3} in the a₁ irreducible representation of the C_{3v} symmetry. Computed at ZORA-BLYP-D3(BJ)/TZ2P

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is, HOMO-LUMO molecular orbital interactions (or electrostatic or dispersion) character regardless of their stability (see $\Delta E_{\rm oi}$ in Table 1 and Fig. 3).

Additionally, it is important to note that dispersion interactions ($\Delta E_{\rm disp}$) are consistently weak, regardless of whether the complex is classified as van der Waals or donor-acceptor complexes in nature. The relative significance of ΔE_{disp} only becomes pronounced when the other stabilizing interactions, electrostatic and orbital contributions, are weakened due to the long-range separation of the interacting pair. This effect is exemplified by the Cl₃B-NCMe adduct, where the dispersion interaction remains small, yet its relative importance increases compared to donor-acceptor interactions (Table 1) Notably, when comparing $Cl_3B \leftarrow NCMe$ and $Cl_3B \cdots NCMe$, ΔE_{oi} varies by more than 50-fold, whereas ΔE_{disp} changes by only a factor of two. This highlights the secondary role of dispersion forces in determining the nature of these interactions, reinforcing the need for a more nuanced classification scheme.

The key distinction among the Lewis pairs lies in the overall interaction strength, particularly whether it is sufficient to overcome the intrinsic strain energy required to bring the Lewis acid and base from their equilibrium geometries to the final complex geometry. As shown in Fig. S1 and S2 (ESI†), stronger Lewis bases exhibit more stabilizing interactions, including greater electrostatic and orbital contributions. Moreover, Pauli repulsion is also enhanced, leading to an earlier deformation of the Lewis acid (vide infra). The interplay between interaction energy ($\Delta E_{\rm int}$) and strain energy ($\Delta E_{\rm strain}$) provides critical insight into the bonding characteristics of Lewis acid-base pairs (Fig. 4). This interplay ultimately determines whether the adduct is strong or weak, shaping its overall bonding characteristics. Strong Lewis bases, such as NH3, enter into a stronger overall interaction, resulting in highly stable adducts because the stabilizing $\Delta E_{\rm int}$ dominates over the destabilizing $\Delta E_{\rm strain}$, even at shorter B-N bond distances. However, this comes at the cost of significant deformation in the Lewis acid, as NH3 induces an unfavorable deformation from the trigonal planar equilibrium geometry earlier along the B-N bond distance. This deformation towards a trigonal pyramidal geometry increases strain energy but is offset by the increasingly stabilizing $\Delta E_{\rm int}$ (Fig. S3 and S4, ESI†), driving the system to adopt a short-bonded minimum. Notably, NH3 does not form a longbonded minimum because it enters into strongly stabilizing covalent interactions at long interatomic distances with the Lewis acids (Fig. 4). In general, once the Lewis acid deforms and the interaction becomes sufficiently strong, forming the short-bonded adduct is accessible energetically.

In contrast, weak Lewis bases, such as N2, result in longbonded and, therefore, weakly bonded adducts, due to extremely weak stabilizing intermolecular interactions. These complexes preserve the near-planar geometry of the Lewis acid because the weakly stabilizing $\Delta E_{\rm int}$ cannot compensate for the ΔE_{strain} required to significantly deform the acid. As a result, the energy minimum van der Waals complex occurs at a longer bond distance where strain energy is minimally destabilizing. Importantly, N2 does not form short-bonded

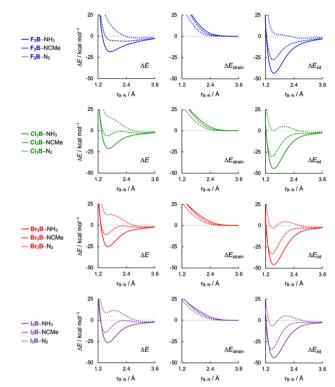


Fig. 4 Activation strain analysis of the X_3B-LB Lewis pairs ($X_3=F_3$, Cl_3 , Br_3 , I_{3} ; LB = NH₃, MeCN, N₂) in C_{3y} symmetry projected onto the forming B-N bond distance, computed at ZORA-BLYP-D3(BJ)/TZ2P

minima because its $\Delta E_{\rm int}$ lacks the strength to overcome the destabilizing strain energy at shorter B-N distances. Furthermore, this general trend can be observed in I₃B···N₂, which features a shallow, short-bonded minimum in its interaction energy. This adduct highlights the nuanced balance between interaction strength and structural deformation in determining bond characteristics.

The moderate Lewis base MeCN exemplifies the intermediate regime in the chemical bonding continuum, bridging the transition from weak van der Waals interactions to strong donor-acceptor complexes. Unlike strong Lewis bases such as NH₃, which form only short, strongly bound adducts, and weak bases like N2, which form only long, weakly bound complexes, MeCN uniquely exhibits both bonding motifs. Depending on the Lewis acid, it can adopt either a long-bonded minimum, stabilized primarily by electrostatic and dispersion forces, or a short-bonded minimum, where orbital interactions (charge transfer) become significant. This dual behavior underscores the continuous nature of chemical bonding, demonstrating that bonding motifs exist on a spectrum rather than as discrete categories.

Rather than representing fundamentally distinct bonding motifs, the difference between van der Waals and donoracceptor complexes arises from the interplay between the rigidity of the Lewis acid and the strength of the Lewis base. By tuning these two factors, one can smoothly transition between these interaction types, highlighting the continuum nature of Lewis acid-base interactions and their versatility in

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molecular design and assembly. As discussed above, the rigidity of the Lewis acid can be modulated by selecting species with more labile bonds, which deform more readily upon bond formation. This effect is evident not only across the boron trihalide series (BX₃) but also in heavier group-13 analogs. For example, the transition from a van der Waals complex in F₃B-N₂ to a donor-acceptor complex in F₃Al-N₂ can be attributed to the reduced rigidity of the Lewis acid as one moves from BF3 to AlF₃, due to the weaker Al-F bonds³⁹ (see Table S1, ESI \dagger).

Additionally, the strain penalty can be reduced by predistorting the Lewis acid, as exemplified by 9-boratriptycene, which adopts a pyramidal geometry favorable for short-bonded adduct formation and can engage in a donor-acceptor interaction even with weak bases like N₂ (Table S1, ESI†). Ultimately, the nature of a Lewis acid-base complex is not binary but reflects a spectrum of interaction strengths, governed by its equilibrium geometry. In general, more rigid Lewis acids or weaker bases tend to favor long-bonded, van der Waals interactions, whereas more flexible acids or stronger bases lead to short-bonded, donor-acceptor complexes.

Conclusions

Using dispersion-corrected relativistic density functional theory, we have comprehensively explored the nature of Lewis acid-base interactions, providing a unified perspective on their bonding characteristics. Our findings reveal that these interactions span a continuum, encompassing both weaker van der Waals interactions at longer distances and stronger donor-acceptor complexes at shorter distances. Importantly, all bonding motifs exhibit a covalent character, with the stability of the resulting complexes determined by the balance of attractive and repulsive forces. The covalent component (ΔE_{oi}) determines whether a complex behaves as a strong or weak Lewis pair: when both the Lewis acid and base are strong, ΔE_{oi} is sufficient to overcome strain, leading to a stable short-bond, donor-acceptor complex. In contrast, when the Lewis acid and base are weak, the long-bonded complex is formed where weaker forces, such as dispersion (ΔE_{disp}), become relatively important. This study highlights the versatility of Lewis acid-base interactions in molecular assembly and offers design principles to tailor these interactions.

Delving deeper, we identify general trends in bond energy and bond length for X₃B-LB Lewis pairs. The strength of the B-N bond varies systematically as the Lewis base transitions from NH₃ to MeCN to N₂. NH₃ forms short-bonded, highly stable adducts, while N2 forms long-bonded, weakly interacting complexes, with MeCN exhibiting intermediate behavior where both the weaker van der Waals and donor-acceptor complexes are observed. This gradation underscores the challenges in rigidly classifying these complexes as donor-acceptor or van der Waals in nature, as they represent a continuum rather than discrete categories. This tunable and unified spectrum is modulated by the strength of the Lewis base or the rigidity of the Lewis acid, offering opportunities for precise control of interaction strength and bonding character.

Ultimately, our work underscores the continuum nature of Lewis acid-base interactions, demonstrating how subtle manipulations of acid or base properties can transition complexes between donor-acceptor and van der Waals-like bonding regimes. This emphasis on the strength rather than the nature of the classification of these interactions not only enriches our understanding of molecular assembly but also establishes a framework for the design of tailored chemical systems. These insights have far-reaching implications for advancing the field of chemical bonding and for developing innovative molecular assemblies and materials.

Author contributions

D. R. S. and T. A. H. conceived the research idea and performed project administration. C. F. G. and T. A. H. supervised the project, and C. F. G. acquired funding. D. R. S. and M. A. J. G. K. performed the data curation, and D. R. S. and L. A. S. performed formal analysis. D. R. S., L. A. S., M. A. J. G. K., C. F. G., and T. A. H. wrote the manuscript.

Data availability

The datasets supporting this article have been uploaded as part of the ESI.†

Conflicts of interest

There are no conflicts to declare.

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